Sheet <u>1</u> of <u>1</u>

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Substitute Form FT (Modified)	69-1:449	S. Department of Commerce Patent and Trademark Office ure Statement	Attorney's Docket No. 07977-263001-US4563	Application No. 09/760,499
Infor	mation Disclos by Applic		Applicant Yamazaki, et al.	
(37 CFR 61 98/b))	Use several sheets	if necessary)	Filing Date January 11, 2001	Group Art Unit 1733

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Examiner Initial	Desig.	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
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Foreign Patent Documents or Published Foreign Patent Applications								
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Initial	ID	Number	Date	Patent Office	Class	Subclass	Yes	No
	AL							
	AM							
	AN							
	AO							
	AP							

	Other D	ocuments (include Author, Title, Date, and Place of Publication)
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Initial	ID	Document
	AQ-	Shimoda, et al., "Surface Free Technology by Laser Annealing (SUFTLA)", IEEE, 1999 (4 pages).
	AR	Duplicade see paper no. 5
	AS	
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Examiner Signature Ali DU	Date Considered 2/21/03				
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.					

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(Modified)		

U.S. Department of Commerce Patent and Trademark Office Attorney's Docket No. 07977/263001/US4563

Application No.
Unknown

Information Disclosure Statement
by Applicant
(Use several sheets if necessary)

Applicant Yamazaki, et al.

Filing Date

Group Art Unit

(37 CFR §1.98(b))

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92	AA	5,757,456	5/26/98	Yamazaki, et al.				
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92	AH	8-96959	4/12/96	Japan			Abstract only		
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}	AN	8-254686	10/1/96	Japan			Abstract only		
92	AO	8-288522	11/1/96	Japan			Abstract only		

Other Documents (include Author, Title, Date, and Place of Publication)					
Examiner	Desig.	_			
Initial	l ID	Document			
92	AP	Shimoda, et al., "Surface Free Technology by Laser Annealing (SUFTLA)", IEDM Technical Digest, 1999, pp.289-292.			
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gon of	2/21/03
EXAMINER: Initials citation considered. Draw line through citation if no	t in conformance and not considered. Include copy of this form with
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